

Supporting Information

Facile synthesis of PtCu₃ alloy hexapods and hollow nanoframes as highly active electrocatalysts for methanol oxidation

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Table S1. ICP-AES data and ECSA of the PtCu hexapods and hollow nanoframes as well as the commercial Pt/C.

Samples	$n_{\text{Pt}}:n_{\text{Cu}}$ *	Pt/Cu atomic ratio	composition	ECSA($\text{m}^2/\text{g}_{\text{pt}}$)**
Hexapods	1:3	1:2.58	Pt ₂₈ Cu ₇₂	34.2
Hollow nanoframes	1:3	1:2.49	Pt ₂₉ Cu ₇₁	73.1
Pt/C	/	/	/	33.9

*: Molar ratio between the Pt and Cu salt precursors fed in the synthesis.

** : The ECSA was calculated from CV curves in Figure S4.

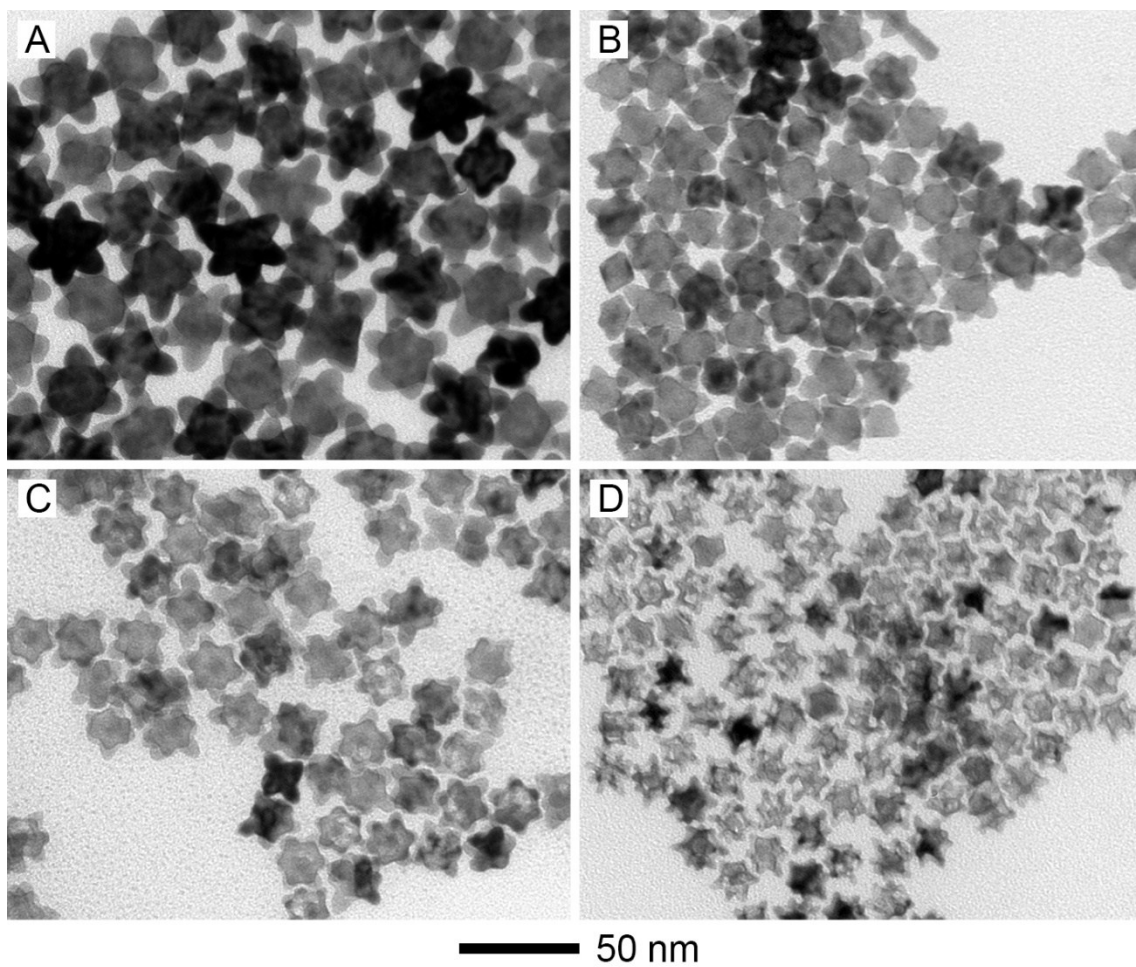


Figure S1. TEM images of the PtCu nanostructures prepared using the standard procedure, except for different temperatures: (a) 220, (b) 210, (c) 200, and (d) 190 °C.

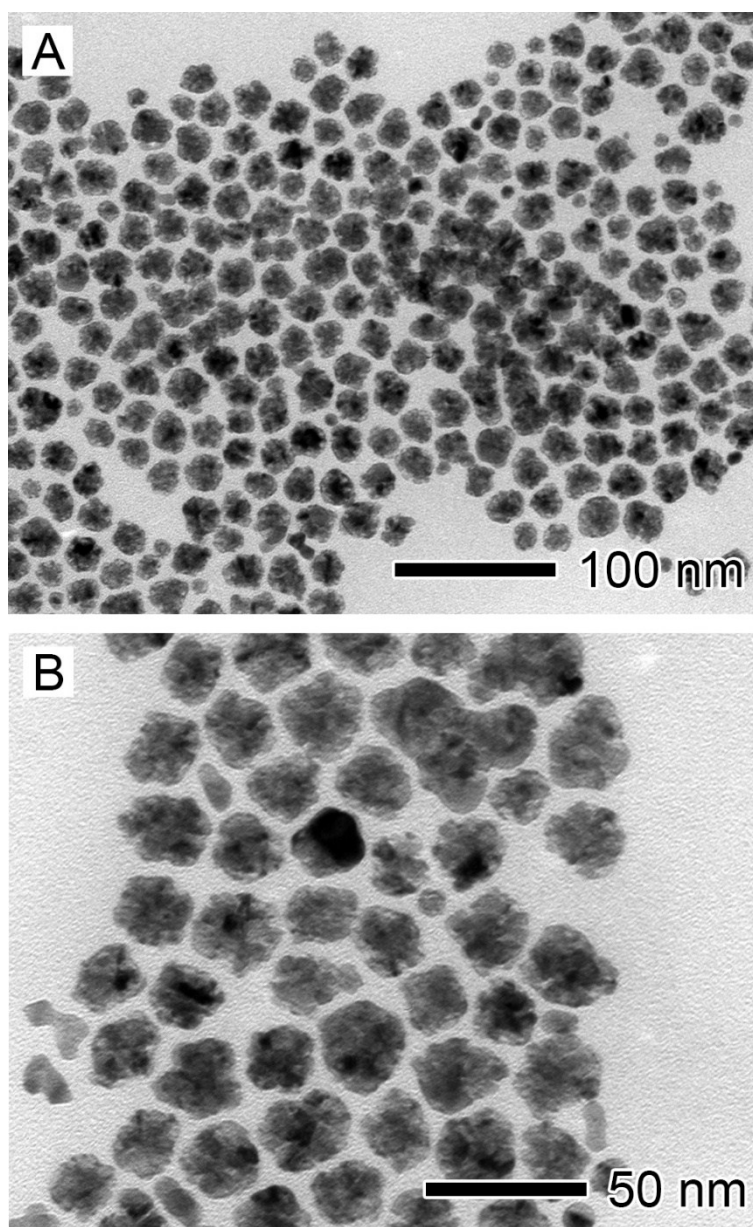


Figure S2. (A, B) TEM images of the PtCu nanocrystals prepared by replacing H_2PtCl_6 with $\text{Pt}(\text{acac})_2$ under otherwise identical experimental conditions.

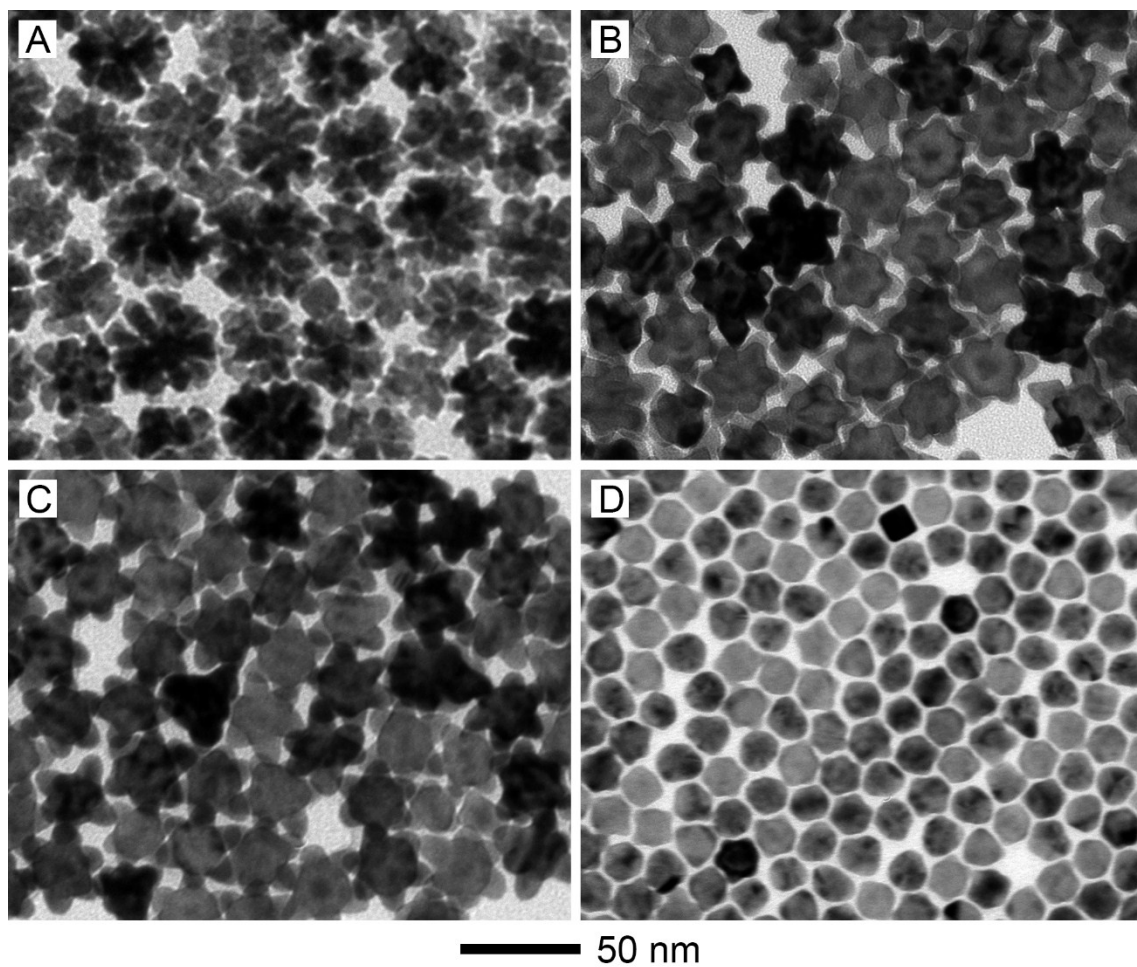


Figure S3. TEM images of PtCu₃ nanocrystals prepared using the standard procedure, except for the different amount of TOPO: (A) in the absence of TOPO, (B) 55 mg, (C) 110 mg and (D) 220 mg.

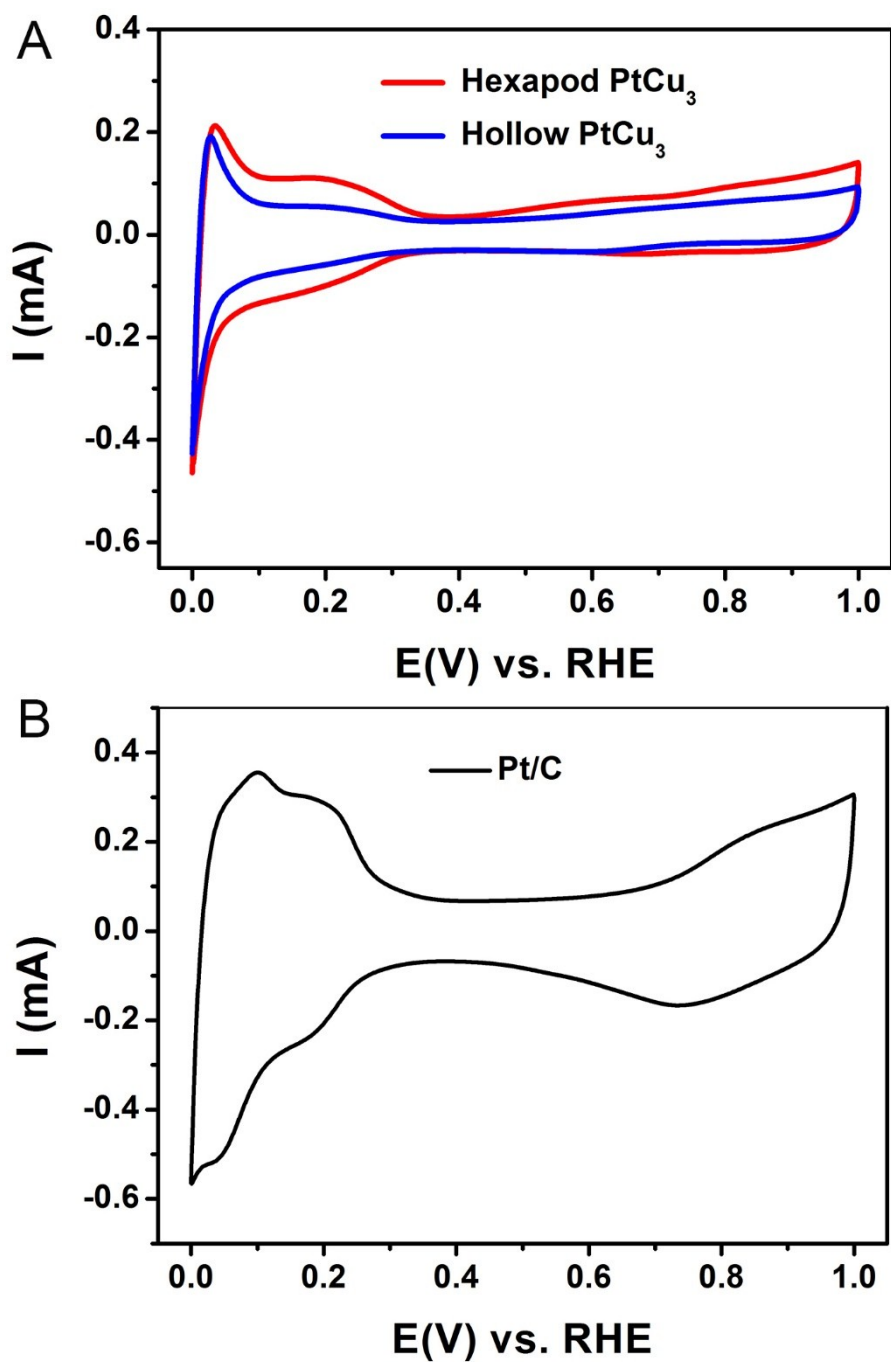


Figure S4. Cyclic voltammograms (CVs) of (A) PtCu₃ alloy hexapods and hollow nanoframes and (B) commercial Pt/C in an Ar-saturated 0.1 M HClO₄ solution at a sweep rate of 50 mV/s.